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TOWNSEND and TOWNSEND and CREW LLP

By: Karl Littau

PATENT  
Attorney Docket No.: AM2119/T21300  
AMAT No.: AM2119/T21300  
TTC No.: 16301M-021300US

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of:

Karl Littau et al.

Application No.: 08/893,917

Filed: July 11, 1997

For: REMOTE PLASMA CLEANING  
SOURCE HAVING REDUCED  
REACTIVITY WITH A SUBSTRATE  
PROCESSING CHAMBER

Customer No.: 57385

Confirmation No. 8435

Examiner: Rudy Zervigon

Technology Center/Art Unit: 1763

AMENDMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Please enter the following amendments and remarks:

**Amendments to Claims** are reflected in the listing of claims that begins on page 2 of this paper.

**Remarks** begin on page 6 of this paper.